



Impact of Scaled Technology on Radiation Testing and Hardening

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Outline

- **Emerging Electronics Technologies**
 - What has changed and is changing in the commercial semiconductor world
- **Effects of Concern**
 - Single Event Effects –SEEs
 - Total Ionizing Dose – TID
- **Challenges to Radiation Testing and Modeling**
 - TID Trends
 - Fault isolation
 - Scaled Geometry
 - Speed
- **Summary/Comments**

*Note: the emphasis of this presentation is digital technologies and SEE.
Some discussion of mitigation implications is included.*

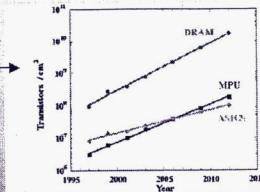


Changes in the Electronics World

- Over the past decade plus, much has changed in the semiconductor world. Among the rapid changes are:

- **Scaling of technology**

- Increased gate/cell density per unit area (as well as power and thermal densities)
- Changes in power supply and logic voltages (<1V)
 - Reduced electrical margins within a single IC
- Increased device complexity
 - More functions per chip: >1 billion gates in a single device
- Speeds to >> GHz (CMOS, SiGe, InP...)



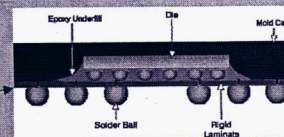
- **Changes in materials**

- Use of antifuse structures, phase-change materials, alternative K dielectrics, Cu interconnects (previous – Al), insulating substrates, ultra-thin oxides, etc...

- **Increased input/output (I/O) in packaging**

- Use of flip-chip, area array packages, etc

- **Increased importance of application specific usage to reliability/radiation performance**



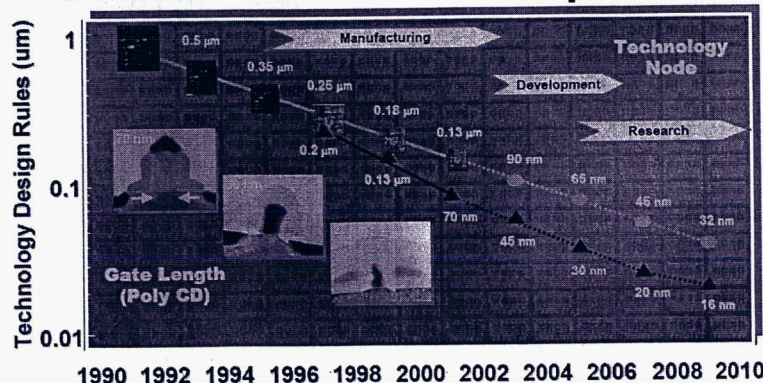
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Mainstream digital – CMOS scaling Semiconductor Roadmap

ledm♦



1990 1992 1994 1996 1998 2000 2002 2004 2006 2008 2010

"Moore's Law" continues to drive semiconductor roadmap

- ~ 30% reduction in transistor size with each new technology

From <10k in 1975 to >1B in 2010

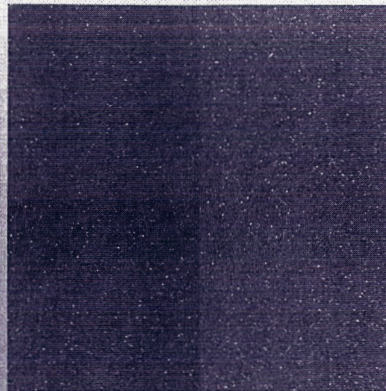
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Radiation Effects and Spacecraft

- Critical areas for design in the natural space radiation environment
 - Long-term effects
 - Total ionizing dose (TID)
 - Displacement damage
 - Transient or single particle effects (Single event effects or SEE)
 - Soft or hard errors
- Mission requirements and philosophies vary to ensure mission performance
 - *What works for a shuttle mission may not apply to a deep-space mission*



An Active Pixel Sensor (APS) imager under irradiation with heavy ions at Texas A&M University Cyclotron

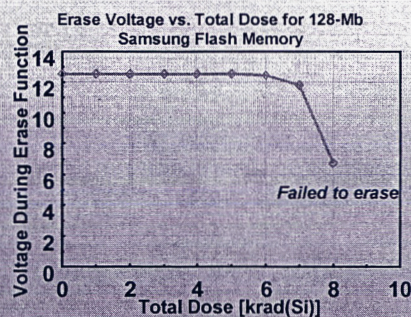
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Total Ionizing Dose (TID)

- Cumulative long term *ionizing* damage due to protons & electrons
- Effects
 - Threshold Shifts
 - Leakage Current
 - Timing Changes
 - Functional Failures
- Unit of interest is krad(material)
- Can *partially* mitigate with shielding
 - Low energy protons
 - Electrons



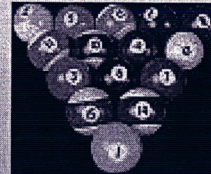
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Displacement Damage (DD)

- Cumulative long term *non-ionizing* damage due to protons, electrons, and neutrons
- Effects
 - Production of defects which results in device degradation
 - May be similar to TID effects
 - Optocouplers, solar cells, CCDs, linear bipolar devices
- Unit of interest is particle fluence for each energy mapped to test energy
 - Non-ionizing energy loss (NIEL) is one means of discussing
- Shielding has some effect - depends on location of device
 - Reduce significant electron and some proton damage



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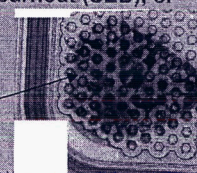
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Single Event Effects (SEEs)

- An SEE is caused by a *single charged particle* as it passes through a semiconductor material
 - Heavy ions
 - Direct ionization
 - Protons for sensitive devices
 - Nuclear reactions for standard devices
 - Optical systems, etc are sensitive to direct ionization
- Effects on electronics
 - If the LET of the particle (or reaction) is greater than the amount of energy or critical charge required, an effect may be seen
 - Soft errors such as upsets (SEUs) or transients (SETs), or
 - Hard (destructive) errors such as latchup (SEL), burnout (SEB), or gate rupture (SEGR)
- Severity of effect is dependent on
 - type of effect
 - system criticality

*Destructive event
in a COTS 120V
DC-DC Converter*



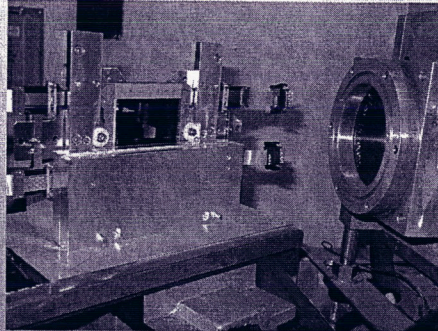
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Typical Ground Sources for Space Radiation Effects Testing

- **Issue: TID**
 - Co-60 (gamma), X-rays, Proton
- **Issue: Displacement Damage**
 - Proton, neutron, electron (solar cells)
- **SEE (GCR)**
 - Heavy ions, Cf
- **SEE (Protons)**
 - Protons ($E > 10$ MeV)
- **SEE (atmospheric)**
 - Neutrons, protons



Wide Field Camera 3 E2V
2k x 4k n-CCD in front of Proton Beam at UC Davis

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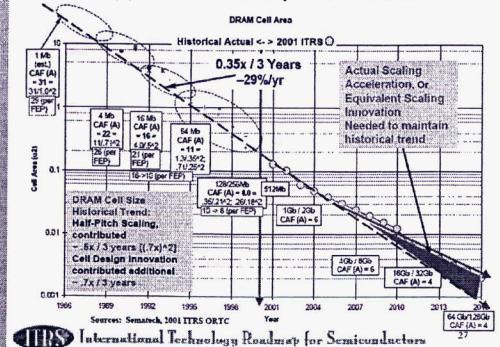
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Total Ionizing Dose (TID) – Technology Trends (1)

- **CMOS Digital Volatile Memory & Logic Technology**
 - Present trend to smaller feature size and lower operating voltages indicates a reduced sensitivity to TID effects; e.g. > 100 krad intrinsic capability for 0.25-micron technology and increasing

DRAM Cell Area History / 2001 ITRS Model



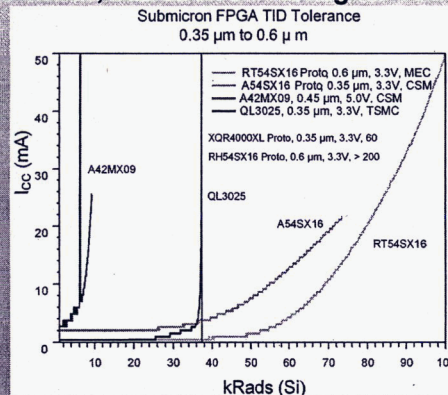
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Total Ionizing Dose (TID) – Technology Trends (2)

- **CMOS Programmable and Non-Volatile Memory Technologies**
 - Both technologies show sensitivity to TID, < 100 krad in some cases, due to need for higher control voltages



FPGA TID Response showing TID Sensitivity

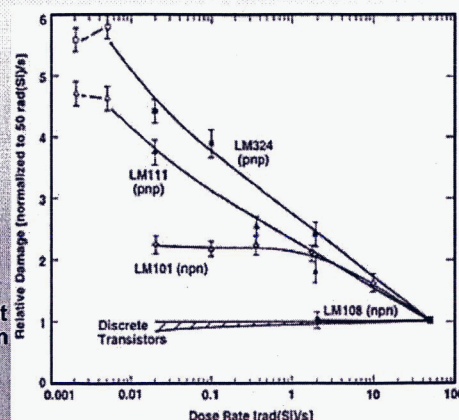
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Total Ionizing Dose (TID) – Technology Trends (3)

- **Bipolar Linear Technologies**
 - Demonstrate extreme sensitivity to TID, parametric & functional fails < < 100 krad
 - Many modern devices subject to Enhanced Low Dose-Rate Sensitivity (ELDRS) Effects
 - It has been predicted that this effect may be seen in scaled CMOS as the scaling approaches a bipolar-like structure (Fleetwood, et al.)



ELDRS Enhancement Factor (EF) vs. dose rate for several bipolar linear circuits

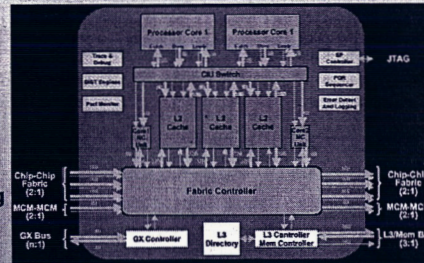
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Radiation Test Challenge – Fault Isolation

- **Issue:** understanding what within the device is causing fault or failure. Identification of a sensitive node.
- **Technology complications**
 - “Unknown” and increased control circuitry (hidden registers, state machines, etc..)
 - Monitoring of external events such as an interrupt to a processor limits understanding of what may have caused the interrupt
 - Example: DRAM
 - » Hits in control areas can cause changes to mode of operation, blocks of errors, changes to refresh, etc...
 - Not all areas in a device are testable



Power4 Processor Architecture

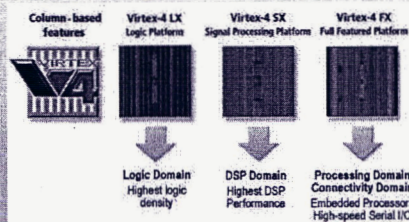
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Fault Isolation –(2)

- **Example: SRAM-based reprogrammable FPGA- measuring sensitivity of user-defined circuit**
 - SEE in configuration area corrupts user circuitry function
 - Can cause halt, continuous misoperation, increased power consumption (bus conflicts), etc.
 - Often the sensitivity of the configuration latches overwhelm user circuitry sensitivity
 - Must have correct configuration to measure user circuit performance
- **Increased number of control structures in a device drives an increasing rate of single event functional interrupts (SEFIs)**



Complex new FPGA architectures include hard-cores: processing, high-speed I/O, DSPs, programmable logic, and configuration latches

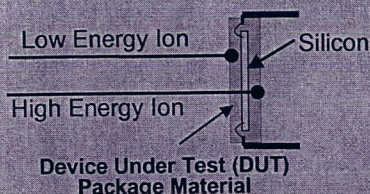
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Fault Isolation –(3)

- **Macrobeam structure: implies probabilistic chance of hitting a single node that may be sensitive**
 - If test is run for SEE, typical heavy ion test run is to 1×10^7 particles/cm².
 - Ex., SDRAM – 512 Mb (5×10^8 bits plus control areas)
 - If all memory cells are the same, no issue. BUT if there are weak cells how do you ensure identifying them?
 - Control logic may be a very small area of the chip. If you fly 1000 devices, area is no longer “small”
 - Difficult to evaluate clock edge sensitivity of a node
 - **Die access (required for most single event testing)**
 - Typical heavy ion single event macrobeam simulators have limited energy range
 - Implies limited penetration through packaged device
 - Access to die typically required
 - Overlayers, metalization, etc must be taken into account



Facility	Ion (Energy)	LET (SI)	Range in Si (μm)	Peak LET
NSCL	Xe (3.2 GeV)	40	272	69
TAMU	Ar (2 GeV)	5.9	390	18

Table assumes ion traverses 1.5 mm plastic LET given in MeV-cm²/mg

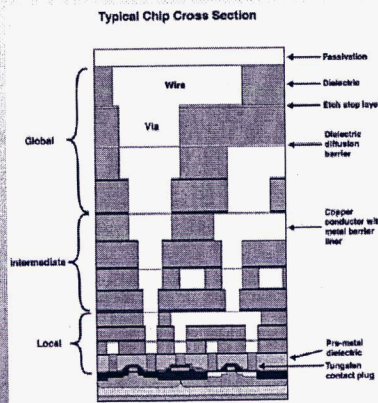
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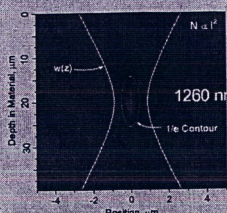


Fault Isolation –(4)

- **Standard microbeam and laser test facilities have similar limitations for range of particle**
 - On older technologies, these facilities are used to determine what structure within a device is causing fault/failure
 - New technique (two-photon absorption - TPA) with the laser is being developed, but is still in research phase
 - New test structures built specifically for test may be required
 - Reduced metalization, special packaging, etc.



TPA is a new technique to overcome some of the test limitations from packaged device and metalization issues.
Courtesy Dale McMorrow, NRL



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Radiation Test Challenge – Geometry

- **Issue: the scaling of feature size and closeness of cells**
- **Technology complications**
 - **Multiple node hits with a single heavy ion track**
 - Because of the closeness of transistors and thinness of the substrate material, a single particle strike can effect multiple nodes potentially defeating hardening schemes.

Litho International Tech Roadmap ledm♦
Lithography Technology Requirements– ITRS 2001 Update

Start Production	2001	2002	2003	2004	2005	2006	2007	2010	2013	2016
Logic Half Pitch (nm)	150nm	130nm	107nm	90nm	80nm	70nm	65nm	45nm	32nm	22nm
Logic Gate in Resist (nm)	90nm	70nm	65nm	53nm	45nm	40nm	35nm	25nm	18nm	13nm
DRAM Half Pitch (nm)	130nm	115nm	100nm	90nm	80nm	70nm	65nm	45nm	32nm	22nm
Contact in Resist (nm)	165nm	140nm	130nm	110nm	100nm	90nm	80nm	55nm	40nm	30nm
Overlay	45nm	40nm	35nm	32nm	28nm	25nm	23nm	18nm	13nm	9nm

Source: ITRS

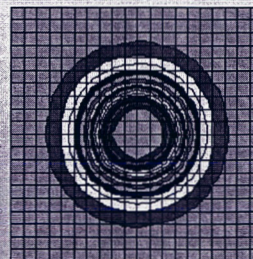
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Geometry Implications (2)

- **Multiple node hits (cont'd)**
 - **Ex., memory array**
 - A single particle strike can spread charge to multiple cells. If the cells are logically as well as physically located
 - Standard memory scrub techniques such as Hamming Code can be defeated
 - This is not new, simply exacerbated by scaling. Traditional SEU modeling considers particle strikes directly on a transistor
 - **Charge spreading for strikes near but not on the transistor can generate errors**
 - Measured error cross-sections may exceed physical cross-sections
 - **Albeit actual individual targets are smaller for a single particle**
 - More targets and the spread of non-target hits implied potentially increased error rates per device
 - **The role of particle directionality and of secondaries requires future use of physics-based particle interaction codes coupled with circuit tools.**
 - GEANT4, MCNPX, etc. are the type of codes required
 - Efforts begun to turn these into tools and not just science codes



Charge spreading from a single particle in an active pixel sensor (APS) array impacts multiple pixels

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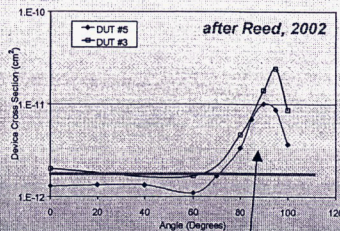
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Geometry Implications (3)

- **High-aspect ratio electronics**

- For “standard” devices, the direction of the secondary particles produced from a proton (or neutron) are considered omnidirectional
- However, for electronics where there is a high-aspect ratio (very thin with long structure), this is not the case
 - The forward spallation of particles when the proton enters the device along the long structure increases the potential error measurement cross-section
 - Test methods and error rate predictions need to consider this



Effects of protons in SOI with varied angular direction of the particle; Blue line represents expected response with “standard” CMOS devices.



Geometry Implications (4)

- **Ultra-thin oxides provide two concerns**

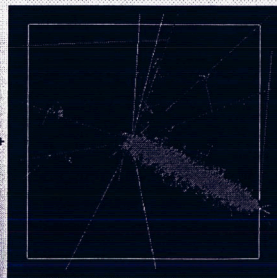
- Single particles rupturing the gate
 - This is a function of the thickness and the current across a gate oxide
- The impact of oxide defects
 - Role for TID

- **Secondaries from packaging material**

- Even on the ground, particle interaction with packaging materials can cause upsets to a sensitive device
 - Ex., Recent FPGA warning of expectation of up to 1 upset/spontaneous reconfiguration a day!

- **Small probability events have increased likelihood of occurring**

- If 1 in a 10^9 particles causes a “larger” LET event or 1 in 10^6 transistors can cause a more complex error
 - With billion plus transistor devices and potential use of >1000 of the same device (re: solid state recorders), small probabilities become finite

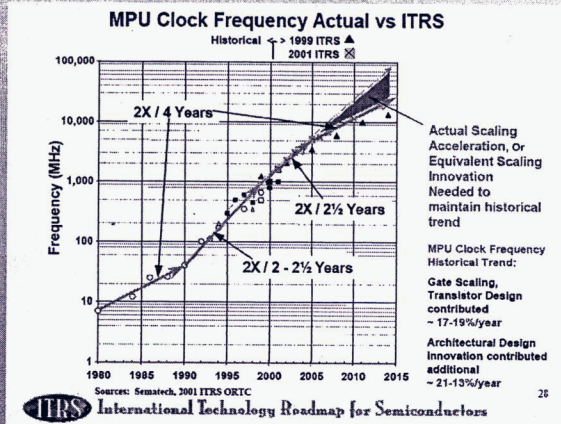


Sample 100 MeV proton reaction in a 5 um Si block. Reactions have a range of types of secondaries and LETs. (after Weller, 2004)



Radiation Test Challenge – Speed Implications

- **Issue: the increasing device speeds (>> GHz) impact testing, test capability requirements, and complicate effects modeling.**



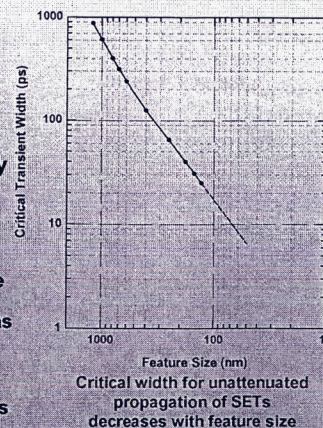
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Speed (2)

- **Technology Complications**
 - **Propagation of single event transients (SETs)**
 - As opposed to a direct upset by a particle strike on a latch-structure, the particle hit causes a transient (think hit on a combinatorial logic or such) that can propagate to change the state of a memory structure down the chain.
 - The transient pulse width can be on the order of picoseconds to nanoseconds (or longer depending on circuit response)
 - » Older, slower devices didn't recognize the transient (i.e., minimum pulse width required for circuit response was greater than that generated by a single particle)
 - » Newer devices can now respond to these hits increasing circuit error rates
 - Transient size in analog devices has been seen to be a partial function of the range of the particle entering the device
 - » Impacts facility usage choices



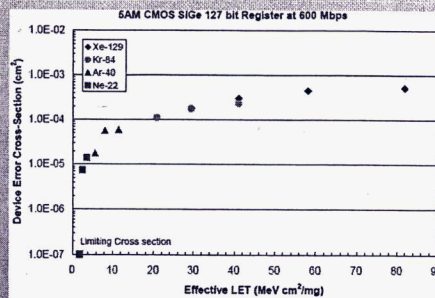
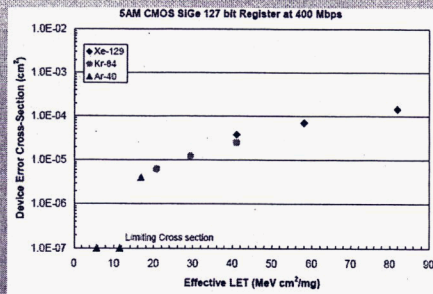
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Speed (3)

- Propagation of SETs (cont'd)
 - Crossover appears in the ~400-500 MHz regime
 - Charge generation can now last for multiple clock cycles
 - Impact is to defeat hardening schemes that assume only a single clock cycle is affected

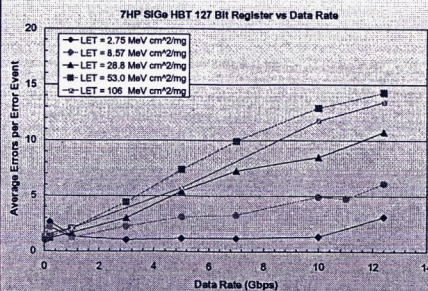


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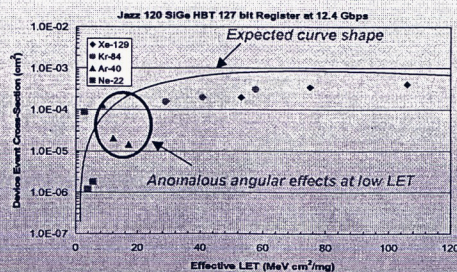
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Speed (4)



Average number of errors noted by a single particle event increases with speed and LET



Effects of heavy ions on SiGe devices at 12 GHz speeds notes anomalous charge collection of this high-speed technology; Drawn line represents expected response with "standard" models.

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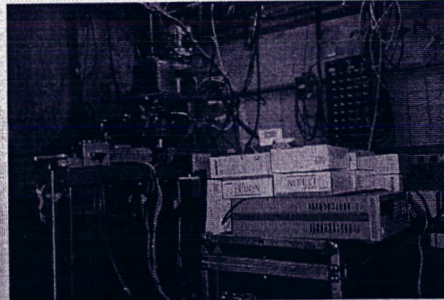
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Speed (5)

Testing at a remote facility requires highly portable test equipment capable of high-speed measurements

- Tester needs to be near the device or utilize high-speed drivers
 - Cable runs between the device under test (DUT) and the tester can be up to 75 feet
- Simple devices like a shift register chain can be tested using bit error rate testers (BERTs)
 - BERTs can run to ~\$1M and tend to be very sensitive to problems from shipping
 - At proton test facilities secondaries are generated (neutrons) that can cause failures in the expensive test equipment if they are located near the DUT
- Self-test techniques for testing devices being developed for shift-registers
 - Modern reconfigurable FPGA-based test boards being developed to test more generic devices



Beware of stray neutrons impinging on your test equipment.

Here, Borax is shown on top of a power supply to absorb neutrons.

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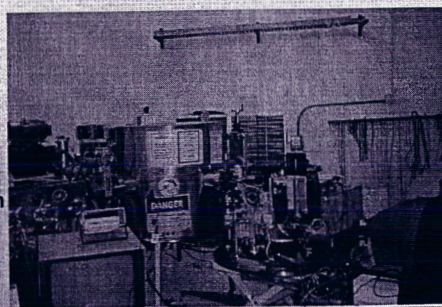
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Speed (6)

- Testing in a vacuum chamber implies mechanical, power/thermal, and hardware mounting constraints
 - High-speed devices often mean high power consumption
 - Issue is mounting of DUT in vacuum chamber and removal of thermal heat
 - Can also be a challenge NOT in a vacuum
 - DUT may need to be custom packaged to allow for thermal issues
 - Active system required for removal of heat

Brookhaven National Laboratories' Single Event Upset Test Facility (SEUTF)



Vacuum Chamber

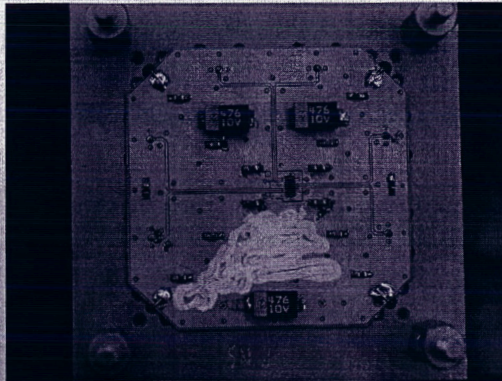
User equipment area

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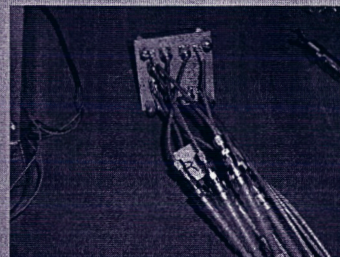


Specialty Packaging for Radiation Test



Front

Back



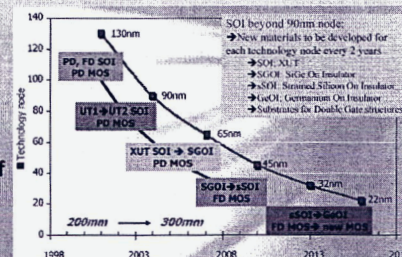
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Summary and Comments

- We have presented a brief overview of **SOME** of the radiation challenges facing emerging scaled digital technologies
 - Implications on using consumer grade electronics
 - Implications for next generation hardening schemes
- Comments
 - Commercial semiconductor manufacturers are recognizing some of these issues as issues for terrestrial performance
 - Looking at means of dealing with soft errors
 - The thinned oxide has indicated improved TID tolerance of commercial products
 - Hardened by "serendipity"
 - Does not guarantee hardness or say if the trend will continue
 - Reliability implications of thinned oxides



Next Generation SOI:
Weak or no body ties will not solve SEU problems

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The Top Five Research/Development Areas Required for Radiation Test and Modeling – Author's Opinions

- **5 Understanding extreme value statistics as it applies to radiation particle impacts**
- **4 High-Energy SEU Microbeam and TPA Laser**
- **3 System Risk Tools**
- **2 Portable High-Speed Device Testers**
- **1 Physics Based Modeling Tool**

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